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WHAT IS CLAIMED IS:

- 1. A semiconductor device comprising a semiconductor chip having a plurality of film electrodes on a rear surface of said semiconductor chip and a plurality of protruding electrodes on a front surface of said semiconductor chip, an insulator resin film covering said semiconductor chip while exposing said film electrodes and a top portion of each of said protruding electrodes, and a conductive film formed on said top portion of said protruding electrodes and configured as a plurality of interconnect lines.
- 2. The semiconductor device as defined in claim 1, wherein said semiconductor chip is mounted on a printed circuit board, with said rear surface opposing said printed circuit board.
- 3. The semiconductor device as defined in claim 1, wherein said interconnect lines are connected to respective terminals of the printed circuit board by wire bonding.
- 4. The semiconductor device as defined in claim 1, wherein each of said protruding electrodes has a base portion having a diameter larger than other portion thereof, and said semiconductor chip is sandwiched between a pair of printed

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- 5 circuit boards.
 - 5. The semiconductor device as defined in claim 1, wherein a portion of a side surface of said semiconductor chip is exposed from said insulator resin film.
 - A method for fabricating a semiconductor device 6. comprising the steps of: adhering onto an adhesive sheet a semiconductor wafer having a plurality of film electrodes on a rear surface of said semiconductor wafer and a plurality of electrodes protruding on a front surface semiconductor wafer, with said rear surface being in contact with said adhesive sheet; dicing said semiconductor wafer to form a plurality of semiconductor chips each including a plurality of said film electrodes and a plurality of said protruding electrodes; extending said adhesive sheet to increase a gap between each two of said semiconductor chips; applying liquid insulator resin to cover said semiconductor chips on said adhesive sheet and fill the gaps therebetween; curing said liquid insulator resin; removing a portion of said insulator resin to expose top surfaces of said protruding electrodes from said insulator resin; forming a conductive film on said top surfaces of said protruding electrodes and on said insulator resin; and dicing said insulator resin and said adhesive sheet to separate said semiconductor chips.

- 7. The method as defined in claim 6, wherein said adhesive sheet is a transparent sheet having an extension property and covered with a UV-cured adhesive layer.
- 8. The method as defined in claim 6, wherein said insulator resin is a UV-cured resin.
- 9. The method as defined in claim 6, wherein said removing step is a grinding step.
- 10. The method as defined in claim 6, wherein each of said protruding electrodes has a base portion having a larger diameter than other portion having a bump shape.
- 11. The method as defined in claim 6, wherein said removing step is a laser irradiation step.
- 12. The method as defined in claim 6, wherein said protruding electrodes are electrically connected to said conductive film via a low-melting-point metal or alloy.
- 13. The method as defined in claim 6, wherein said semiconductor wafer dicing step is a half-cut dicing step.